

MAY 24 2004

TRANSMITTAL OF FORMAL DRAWINGS

Docket No.
SLA0673

In Re Application Of: **Tingkai Li, Sheng Teng Hsu, David R. Evans and Bruce D. Ulrich**

Serial No.	Filing Date	Batch No.	Examiner	Art Unit
10/606,057	06/25/2003		Walter Lee Lindsay Jr.	2812

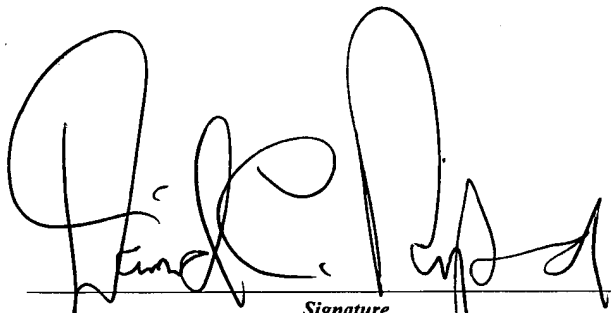
Invention: **MOCVD Selective Deposition of C-Axis Oriented Pb5Ge3O11 Thin Films on High k Gate Oxides**

Address to:
**Assistant Commissioner for Patents
Washington, D.C. 20231**

Transmitted herewith are:

2 sheets of formal drawing(s) for this application.

Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c) on the reverse side of the drawing.



Signature

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Dated: May 21, 2004

I certify that this document and attached formal drawings are being deposited on May 21 2004 with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

Signature of Person Mailing Correspondence

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